



US 20040160568A1

(19) **United States**

(12) **Patent Application Publication** (10) **Pub. No.: US 2004/0160568 A1**

Kim et al.

(43) **Pub. Date:** **Aug. 19, 2004**

(54) **LIQUID CRYSTAL DISPLAY DEVICE AND METHOD OF FABRICATING THE SAME**

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(21) Appl. No.: **10/779,842**

(22) Filed: **Feb. 18, 2004**

**Related U.S. Application Data**

(63) Continuation of application No. 10/316,109, filed on Dec. 11, 2002, now Pat. No. 6,724,458.

(30) **Foreign Application Priority Data**

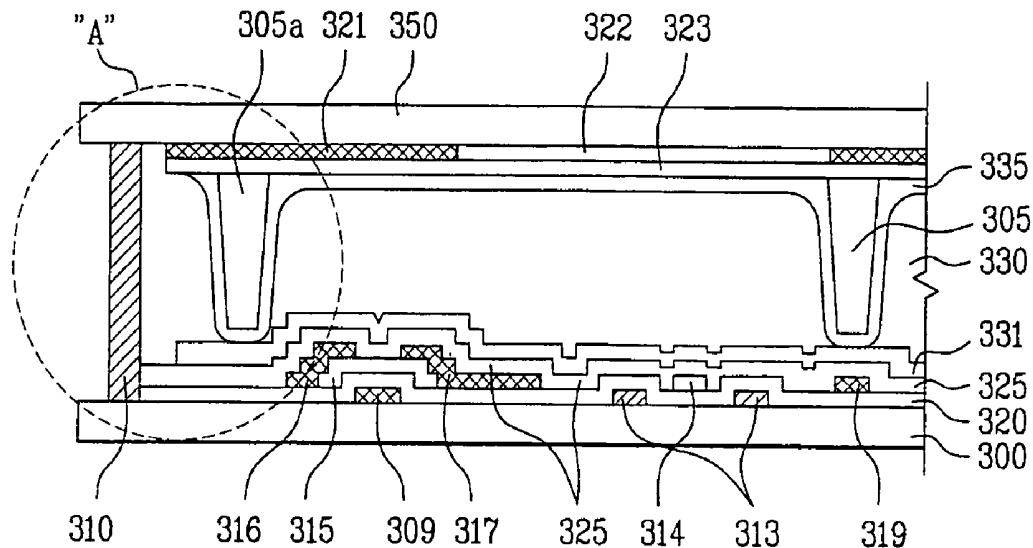
Dec. 22, 2001 (KR) ..... P2001-083218

**Publication Classification**

(51) **Int. Cl. 7** ..... **G02F 1/1339**  
(52) **U.S. Cl.** ..... **349/156**

(57) **ABSTRACT**

A liquid crystal display device and a method of fabricating the same are disclosed in the present invention. The device includes first and second substrates bonded to each other, each having a liquid crystal display panel region divided into an active area and a dummy area, a sealant in a periphery of the liquid crystal display panel region bonding the first and second substrates to each other, at least one column spacer both in the dummy area and outside the liquid crystal display panel region maintaining a cell gap between the first and second substrates, and a liquid crystal layer between the first and second substrates.



# FIG. 1

## Related Art

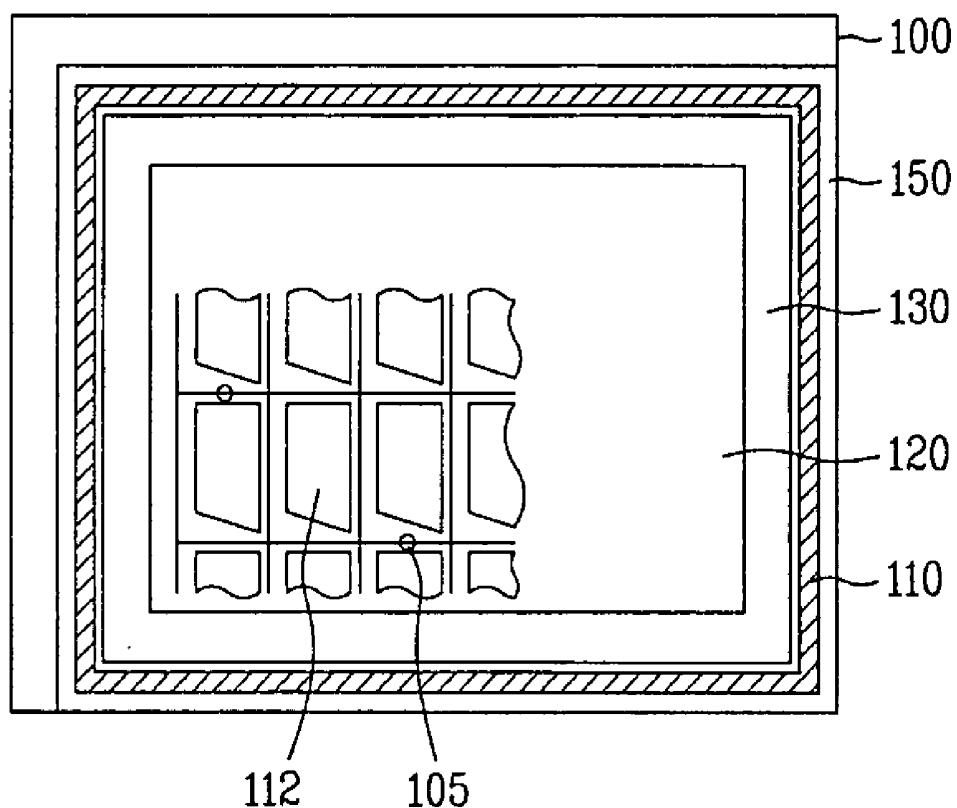


FIG. 2A  
Related Art

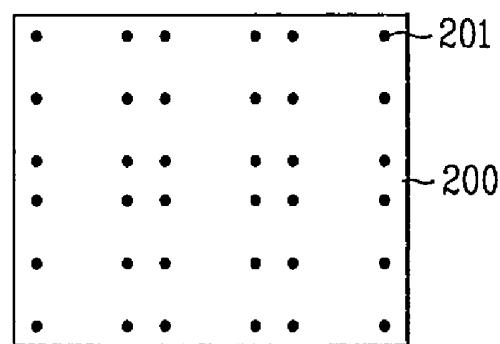


FIG. 2B  
Related Art

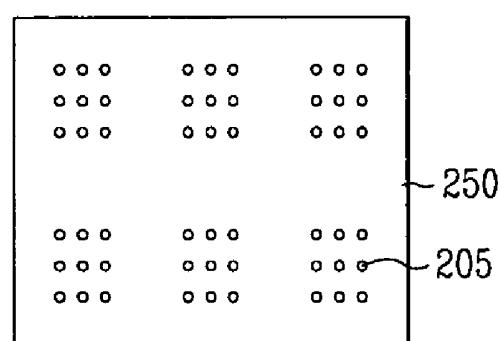


FIG. 2C  
Related Art

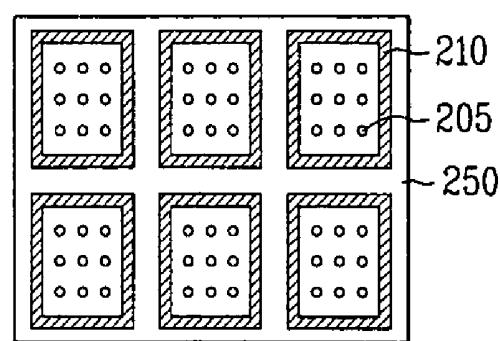


FIG. 2D  
Related Art

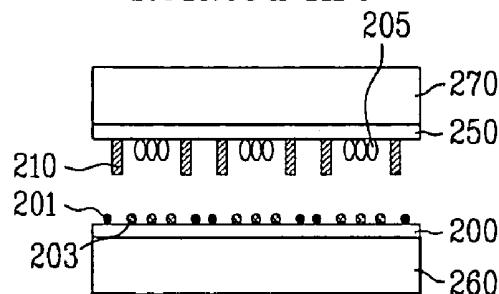


FIG. 2E  
Related Art

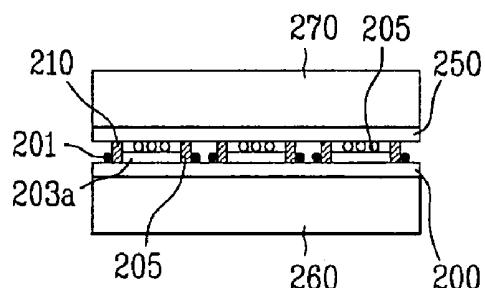


FIG. 2F  
Related Art

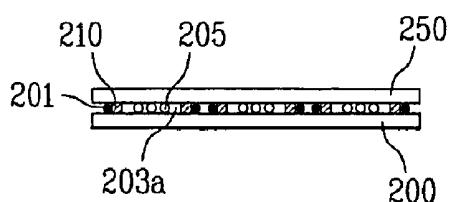


FIG. 2G  
Related Art

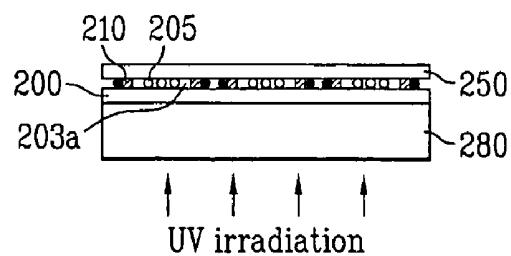


FIG. 3A

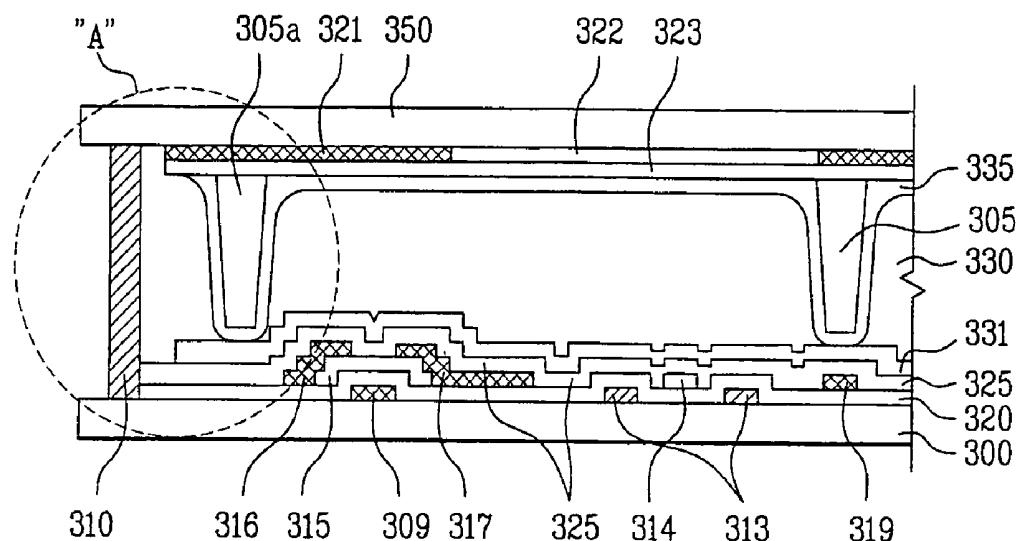


FIG. 3B

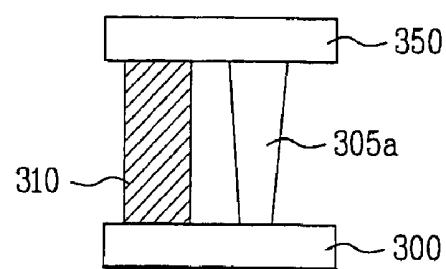


FIG. 3C

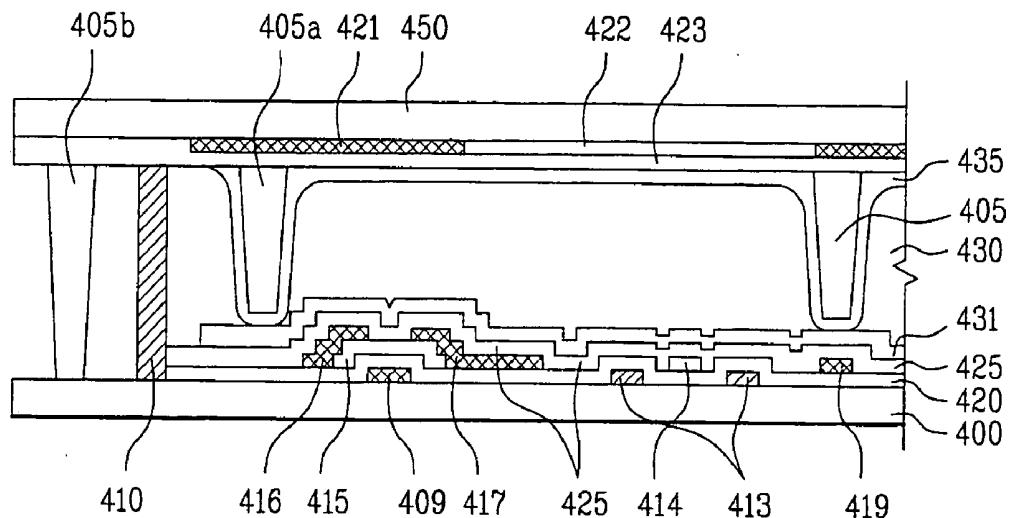


FIG. 3D

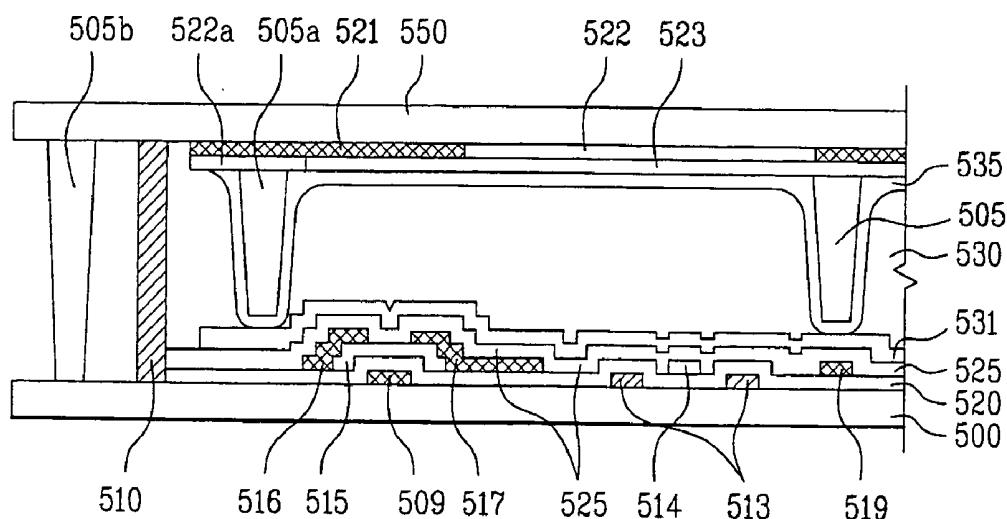


FIG. 3E

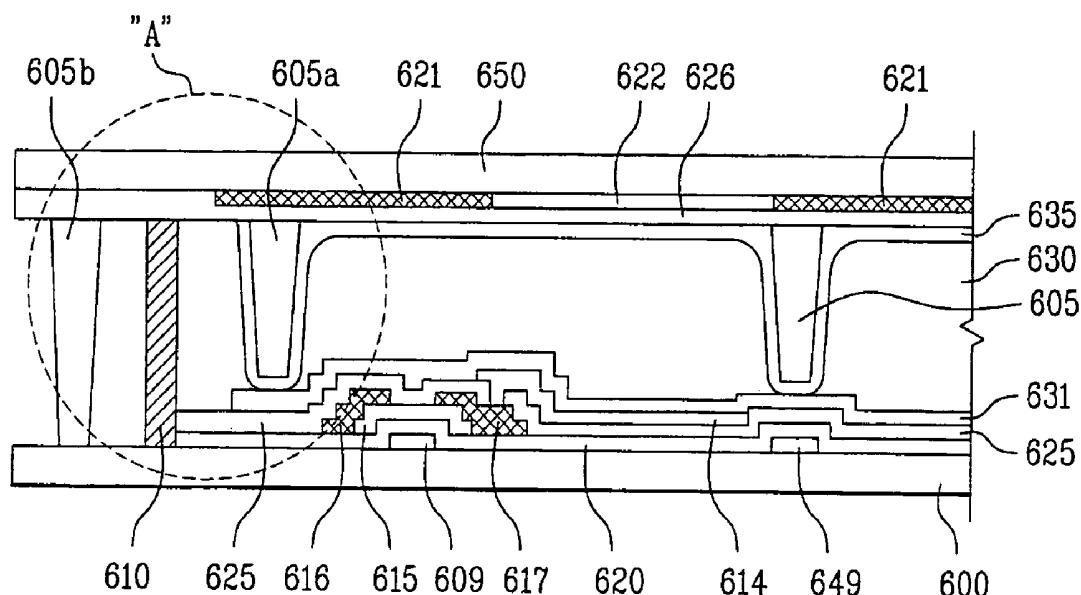


FIG. 3F

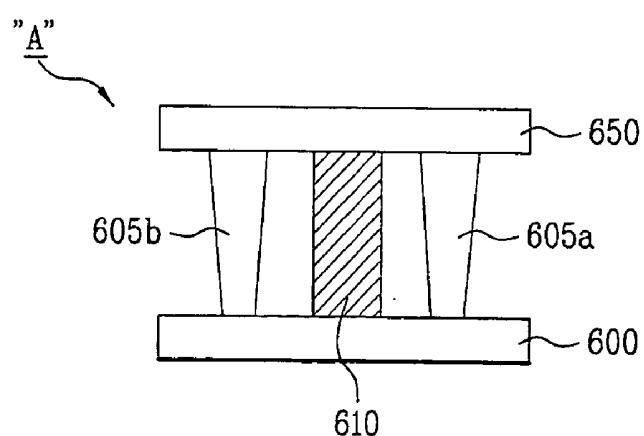


FIG. 4A

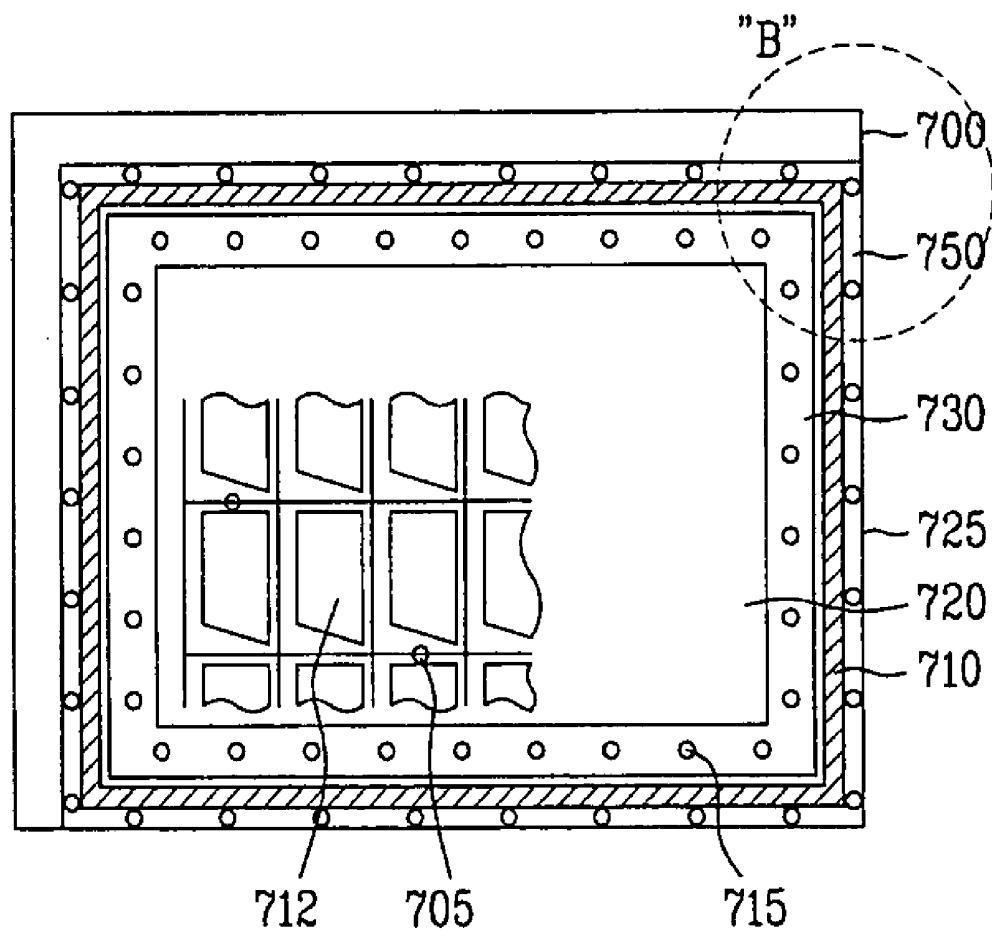


FIG. 4B

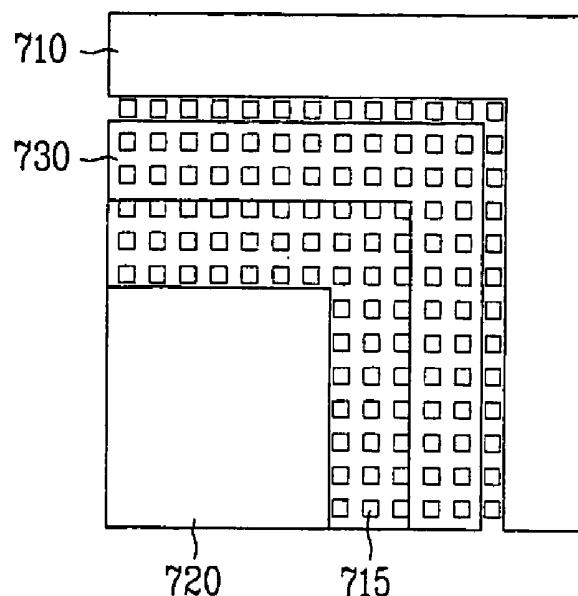


FIG. 4C

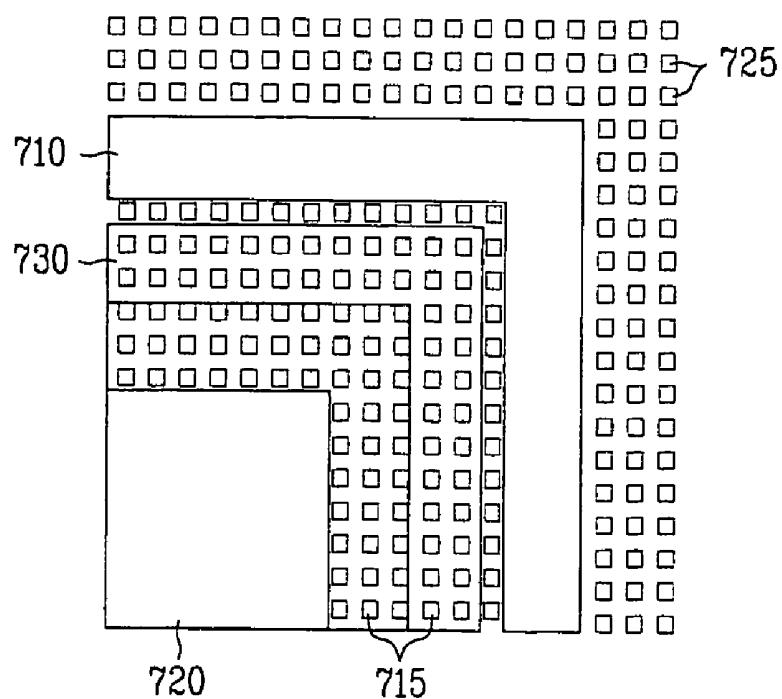


FIG. 5A

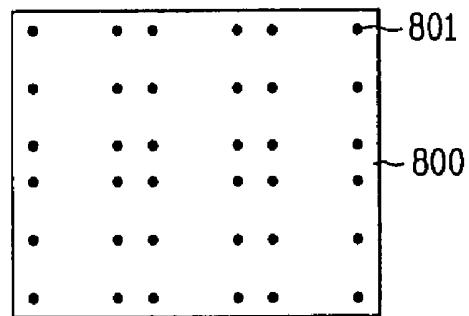


FIG. 5B

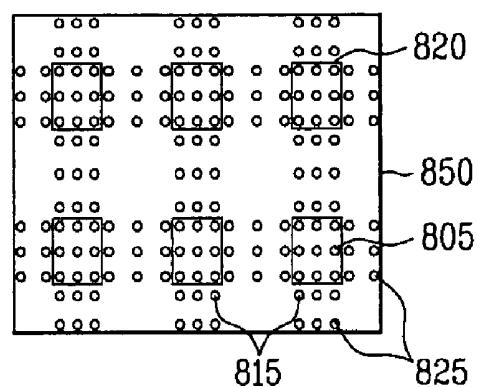


FIG. 5C

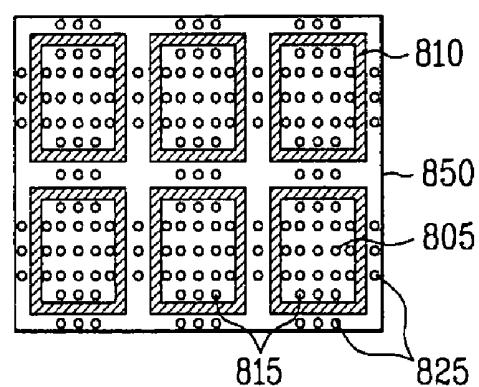


FIG. 5D

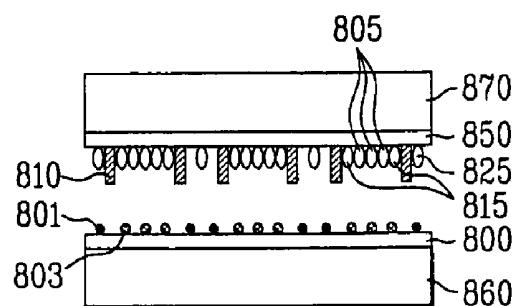


FIG. 5E

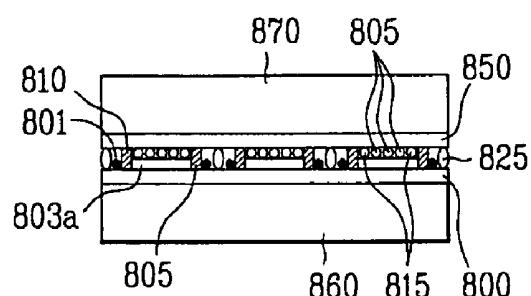


FIG. 5F

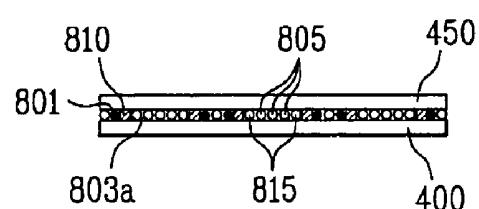
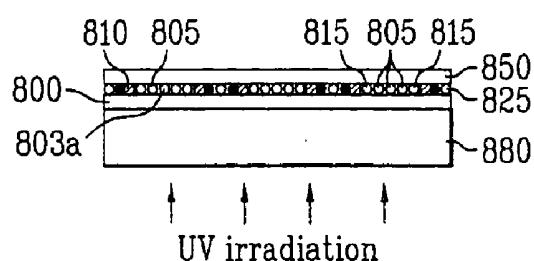


FIG. 5G



## LIQUID CRYSTAL DISPLAY DEVICE AND METHOD OF FABRICATING THE SAME

[0001] This application is a continuation of U.S. patent application Ser. No. 10/316,109, filed Dec. 11, 2002, which is hereby incorporated by reference. This application further claims the benefit of the Korean Application No. P2001-083218 filed on Dec. 22, 2001, which is hereby incorporated by reference.

### BACKGROUND OF THE INVENTION

[0002] 1. Field of the Invention

[0003] The present invention relates to a display device, and more particularly, to a liquid crystal display device and a method of fabricating the same. Although the present invention is suitable for a wide scope of applications, it is particularly suitable for providing a uniform cell gap in the liquid crystal display device.

[0004] 2. Discussion of the Related Art

[0005] Generally, a liquid crystal display device has characteristics, such as low-voltage driving, low power consumption, full-color implementation, thin and compact size, and the like. Thus, it has been widely used for calculators, notebook computers, electronic watches, PC monitors, aircraft gauges, personal mobile terminals, mobile phones, etc.

[0006] Screens of liquid crystal display devices get wider and larger in size. In fabricating wide-screen liquid crystal display devices, a related art method for forming a liquid crystal layer by using vacuum injection takes too much time. Hence, a liquid crystal dropping method of dispensing liquid crystal droplets on a substrate under a vacuum condition has been widely used to resolve the problems in the conventional fabrication process.

[0007] When the liquid crystal layer is formed by the liquid crystal dropping method, a fabricating time can be reduced. The liquid crystal dropping method uses a UV-ray hardening sealant for bonding upper and lower substrates to each other.

[0008] The UV-ray hardening sealant is provided by mixing acrylate resin with a photo-hardener, which becomes a radical when a UV-ray is irradiated thereto at a predetermined ratio. The photo-hardener reacts with the acrylate to form polymer having strong adhesion to the glass substrate.

[0009] A spacer is used to maintain a uniform cell gap when the substrates are bonded to each other. The spacer types include a ball spacer scattered on the substrate and a column spacer formed on the substrate. The ball spacer may alter the cell gap when applied to a wide area. For this reason, the column spacer is mainly used.

[0010] When bonding the two substrates to each other by using a UV-ray hardening sealant, portions of the substrates with the sealant formed thereon are strongly bonded to each other. On the other hand, adhesion of the array portions of the substrates is weaker than that of the portions with the sealant. Thus, a stress is generated between the substrates.

[0011] A liquid crystal display device and a method of fabricating the same according to a related art are explained by referring to the attached drawings as follows.

[0012] FIG. 1 illustrates a layout of a liquid crystal display device by using a related art liquid crystal dropping method.

[0013] As shown in FIG. 1, a thin film transistor (TFT) array is formed in a liquid crystal display panel region on a first substrate 100. A silver (Ag) pattern for applying voltage to a terminal Vcom is formed on the periphery of the liquid crystal display panel region. Liquid crystal droplets are then dispensed onto the liquid crystal display panel region. The liquid crystal display panel region has an active area 120 and a dummy area 130.

[0014] Meanwhile, a color filter pattern is formed in the liquid crystal display panel region on a second substrate 150. Column spacers 105 are formed in the active area 120 to correspond to a wiring part excluding a pixel region 112 of the first substrate 100. The column spacers 105 formed on the second substrate 150 are then attached to the second substrate 150. After forming the column spacers 105, a UV-ray hardening sealant pattern 110 is formed on the periphery of the liquid crystal display panel region on the second substrate 150.

[0015] Subsequently, a liquid crystal display panel is prepared by bonding the first and second substrates 100 and 150 to each other. A UV-ray is then applied to the UV-ray hardening sealant 110 to harden the UV-ray hardening sealant 110.

[0016] The column spacers 105 maintain a uniform cell gap in the active area 120 on the entire surface of the liquid crystal display device. Meanwhile, due to its strong adhesion, the UV-ray hardening sealant pattern 110 pulls the first and second substrates 100 and 150. Therefore, a portion where the sealant pattern 110 is formed generates a stress greater than that in the active area 120. Moreover, since the UV-ray hardening sealant pattern 110 pulls the first and second substrates 100 and 150, the cell gap around the sealant pattern 110 may vary in accordance with the amount of the sealant pattern 110.

[0017] FIGS. 2A to 2G illustrate layouts and cross-sectional views illustrating a process of fabricating a liquid crystal display device using a related art liquid crystal dropping method.

[0018] A plurality of liquid crystal display panel regions are arranged on parent substrates (i.e., first and second substrates). As shown in FIG. 2A, a plurality of silver (Ag) patterns 201 are formed on the periphery of each liquid crystal display panel region on a first substrate 200.

[0019] Referring to FIG. 2B, column spacers 205 are formed in an active area of each liquid crystal display panel region on a second substrate 250 to correspond to a wiring part of the first substrate 200.

[0020] Referring to FIG. 2C, a UV-ray hardening sealant pattern 210 is formed on the periphery of each liquid crystal display panel region on the second substrate 250.

[0021] As shown in FIG. 2D, a predetermined amount of liquid crystal droplets 203 are dispensed on each liquid crystal display panel region of the first substrate 200. The second substrate 250 is disposed over the first substrate 200 to face into a bonding machine. The first and second substrates 200 and 250 are then bonded to each other. More specifically, the second substrate 250 is fixed to an upper stage 270 of the bonding machine, allowing movement in

the Z-axis direction (i.e., vertical direction). Meanwhile, the silver (Ag) patterns **201** are disposed on the periphery of the UV-ray hardening sealant **210** on the second substrate **250**. And, the first substrate **200** is fixed to a lower stage **260** of the bonding machine, allowing movement in the X and Y axes directions (i.e., horizontal direction).

[0022] Referring to **FIG. 2E**, the upper and lower stages **270** and **260** are aligned to each other, thereby achieving a vacuum condition within the bonding machine. Hence, the first and second substrates **200** and **250** are bonded to each other. After bonding the substrates **200** and **250** in the bonding machine under a vacuum condition, a first cell gap is formed, and then the bonded substrates **200** and **250** are exposed to the atmospheric pressure.

[0023] As shown in **FIG. 2F**, after the bonded substrates **200** and **250** having the first gap are exposed to the atmospheric pressure, a pressure difference between inside the liquid crystal display panel and the atmospheric pressure generates a second cell gap between the bonded substrates **200** and **250**. In this case, the dispensed liquid crystal droplets become a liquid crystal layer **203a** having a uniform thickness.

[0024] Referring to **FIG. 2G**, the bonded substrates **200** and **250** are placed on a quartz stage **280**. A UV-ray is then irradiated to the bonded substrates on a lower side of the first substrate **200** in order to harden the UV-ray hardening sealant pattern **210**.

[0025] The liquid crystal display device and the method of fabricating the same have the following problems or disadvantages.

[0026] The UV-ray hardening sealant pulls the bonded substrates while being hardened, thereby generating a stress between the active area part and the sealant pattern part. Since, the UV-ray hardening sealant pulls the bonded substrates while being hardened, the cell gap around the sealant pattern is altered in accordance with the quantity of the sealant pattern.

#### SUMMARY OF THE INVENTION

[0027] Accordingly, the present invention is directed to a liquid crystal display device and a method of fabricating the same that substantially obviates one or more of problems due to limitations and disadvantages of the related art.

[0028] Another object of the present invention is to provide a liquid crystal display device and a method of fabricating the same that enable to maintain a uniform cell gap in a sealant formed portion.

[0029] Another object of the present invention is to provide a liquid crystal display device and a method of fabricating the same that enable to reduce a stress caused by a sealant.

[0030] In order to achieve the above objects, at least one column spacer in the present invention is formed on the periphery of a sealant pattern.

[0031] Additional features and advantages of the invention will be set forth in the description which follows and in part will be apparent from the description, or may be learned by practice of the invention. The objectives and other advantages of the invention will be realized and attained by

the structure particularly pointed out in the written description and claims hereof as well as the appended drawings.

[0032] To achieve these and other advantages and in accordance with the purpose of the present invention, as embodied and broadly described, a liquid crystal display device includes first and second substrates bonded to each other, each having a liquid crystal display panel region divided into an active area and a dummy area, a sealant in a periphery of the liquid crystal display panel region bonding the first and second substrates to each other, at least one column spacer both in the dummy area and outside the liquid crystal display panel region maintaining a cell gap between the first and second substrates, and a liquid crystal layer between the first and second substrates.

[0033] In another aspect of the present invention, a liquid crystal display device includes a first substrate having a liquid crystal display panel region divided into an active area and a dummy area, a second substrate bonded to the first substrate, a plurality of first column spacers in the liquid crystal display panel region, a sealant in a periphery of the liquid crystal display panel region to bond the first and second substrates to each other, a plurality of second column spacers outside the liquid crystal display panel region around the sealant, and a liquid crystal layer between the first and second substrates.

[0034] In another aspect of the present invention, a liquid crystal display device includes first and second substrates bonded to each other, each having a liquid crystal display panel region divided by an active area and a dummy area, at least one first column spacer in the active area, at least one second column spacer in the dummy area, at least one third column spacer outside the liquid crystal display panel region, a sealant in a periphery of the liquid crystal display panel region bonding the first and second substrates to each other, and a liquid crystal layer between the first and second substrates.

[0035] In a further aspect of the present invention, a method of fabricating a liquid crystal display device includes preparing first and second substrates having a liquid crystal display panel region divided into an active area and a dummy area, dispensing at least one liquid crystal droplet in the liquid crystal display panel region of the first substrate, forming at least one first column spacer in the active area of the second substrate, forming at least one second column spacer in the dummy area of the second substrate, forming at least one third column spacer outside the liquid crystal display panel region of the second substrate, forming a sealant in a periphery of the liquid crystal display panel region of the second substrate, and bonding the first and second substrates to each other.

[0036] It is to be understood that both the foregoing general description and the following detailed description are exemplary and explanatory and are intended to provide further explanation of the invention as claimed.

#### BRIEF DESCRIPTION OF THE DRAWINGS

[0037] The accompanying drawings, which are included to provide a further understanding of the invention and are incorporated in and constitute a part of this application, illustrate embodiments of the invention and together with the description serve to explain the principle of the invention.

[0038] In the drawings:

[0039] FIG. 1 illustrates a layout of a liquid crystal display device fabricated by using a related art liquid crystal dropping method;

[0040] FIGS. 2A to 2G illustrate layouts and cross-sectional views illustrating a process of fabricating a liquid crystal display device using the related art liquid crystal dropping method;

[0041] FIG. 3A illustrates a cross-sectional view illustrating a liquid crystal display device for a horizontal electrical field system according to a first embodiment of the present invention;

[0042] FIG. 3B schematically illustrates a magnified view of an area "A" in FIG. 3A;

[0043] FIG. 3C illustrates a cross-sectional view illustrating a liquid crystal display device for a horizontal electrical field system according to a second embodiment of the present invention;

[0044] FIG. 3D illustrates a cross-sectional view illustrating a liquid crystal display device for a horizontal electrical field system according to a third embodiment of the present invention;

[0045] FIG. 3E illustrates a cross-sectional view illustrating a liquid crystal display device for a horizontal electrical field system according to a fourth embodiment of the present invention;

[0046] FIG. 3F schematically illustrates a magnified view of an area "A" in FIG. 3E;

[0047] FIG. 4A illustrates a layout of a liquid crystal display device fabricated by using a liquid crystal dropping method according to the present invention;

[0048] FIG. 4B schematically illustrates a magnified view of an area "B" in FIG. 4A according to the first embodiment of the present invention;

[0049] FIG. 4C schematically illustrates a magnified view of an area "B" in FIG. 4A according to the second to fourth embodiments of the present invention; and

[0050] FIGS. 5A to 5G illustrate layouts and cross-sectional views illustrating a process of fabricating a liquid crystal display device using a liquid crystal dropping method according to the present invention.

#### DETAILED DESCRIPTION OF THE ILLUSTRATED EMBODIMENTS

[0051] Reference will now be made in detail to the illustrated embodiments of the present invention, examples of which are illustrated in the accompanying drawings. Whenever possible, the same reference numbers will be used throughout the drawings to refer to the same or like parts.

[0052] FIG. 3A illustrates a cross-sectional view illustrating a liquid crystal display device for a horizontal electrical field system according to a first embodiment of the present invention.

[0053] Referring to FIG. 3A, a metal layer is deposited on a first substrate 300. A plurality of gate lines (not shown) are formed on the first substrate 300 through photolithography

and etching processes. A plurality of gate electrodes 309 and a plurality of common electrodes 313 are formed in a thin film transistor region.

[0054] A gate insulating layer 320 is formed on the entire surface including the gate and common electrodes 309 and 313. A semiconductor layer 315 for an active layer is formed on the gate insulating layer 320.

[0055] A plurality of data lines 319 are formed on the gate insulating layer 320. Simultaneously, source and drain electrodes 316 and 317 are formed on both sides of the semiconductor layer 315. Additionally, a pixel electrode 314 is formed on the gate insulating layer 320 in parallel with the common electrode and adjacent to the source and drain electrodes 316 and 317.

[0056] And, a passivation layer 325 is formed on the entire surface including the source electrode 316, the drain electrode 317, the data line 319, and the pixel electrode 314. A first alignment layer 331 is then formed on the passivation layer 325.

[0057] Meanwhile, a black matrix 321 and a color filter layer 322 are formed in the liquid crystal display panel region having the active area 720 and the dummy area 730 on a second substrate 350. An overcoat layer 323 is formed on the upper surface of the black matrix 321 and the color filter layer 322, so as to reduce a surface step difference thereof. The overcoat layer 323 is then patterned. Herein, the black matrix 321 is formed of one of Cr, CrO<sub>x</sub>, and black resin.

[0058] One or more column spacers 305 are formed on the overcoat layer 323 inside an array region of the second substrate 350. Simultaneously, a plurality of column spacers 305a are formed on the overcoat layer 323 outside the array region and inside a UV-ray hardening sealant pattern 310, which will be formed in a later process. A second alignment layer 335 is then formed on the column spacers 305 and 305a as well as the overcoat layer 323.

[0059] Subsequently, a UV-ray hardening sealant pattern 310 is formed on the second substrate 350 at the periphery of the column spacers. Liquid crystal droplets are dispensed on the first substrate 300, which is treated for alignment. The second substrate 350 is disposed on the upper surface of the first substrate 300. The first and second substrates 300 and 350 are then bonded to each other.

[0060] FIG. 3B schematically illustrates a magnified view of an area "A" in FIG. 3A.

[0061] As shown in FIG. 3B, the column spacer 305a maintains a cell gap between the two substrates 300 and 350 that will be bonded to each other by the UV-ray hardening sealant 310.

[0062] FIG. 3C illustrates a cross-sectional view illustrating a liquid crystal display device for a horizontal electrical field system according to a second embodiment of the present invention. Unlike in FIG. 3A, the overcoat layer 423 is not patterned in FIG. 3C.

[0063] As shown in FIG. 3C, a first column spacer 405 is formed inside an array region on the second substrate 450. Simultaneously, a second column spacer 405a is formed on the inner surface of the UV-ray hardening sealant pattern 410 on the overcoat layer 423. Simultaneously, a third

column spacer **405b** is also formed on the second substrate on the outer surface of the UV-ray hardening sealant pattern **410**.

[0064] Subsequently, a second alignment layer **435** is formed on the overcoat layer **423** corresponding to the surfaces of the first and second column spacers **405** and **405a** and the inside of the UV-ray hardening sealant **410**. And, the UV-ray hardening sealant **410** is formed on the overcoat layer **423** between the second column spacers **405a** and the third column spacers **405b**.

[0065] Thereafter, liquid crystal droplets are dispensed on the first substrate **400** treated with alignment. The second substrate **450** is disposed over the first substrate **400**. Then, the first and second substrates **400** and **450** are bonded to each other.

[0066] As described above, at least two second and third column spacers **405a** and **405b** are formed at each side, more specifically, the inside and the outside of the UV-ray hardening sealant **410**.

[0067] FIG. 3D illustrates a cross-sectional view illustrating a liquid crystal display device for a horizontal electrical field system similar to those in FIGS. 3A and 3C. However, FIG. 3D differs from FIG. 3C in that the overcoat layer **423** is patterned to be formed inside the array region only. And, a dummy color filter layer **522a** is formed on the periphery of the array region within the overcoat layer **523**.

[0068] In FIG. 3D, a first column spacer **505** is formed on the overcoat layer **523** inside the array region of the second substrate. Simultaneously, a second column spacer **505a** is formed on the dummy color filter layer **522a** formed on the periphery of the array region. Moreover, a third column spacer **505b** is formed on the second substrate **550** on the periphery of the UV-ray hardening sealant pattern **510**.

[0069] Meanwhile, a second alignment layer **535** is formed on the overcoat layer **523** and the first and second column spacers **505** and **505a** in the liquid crystal display panel region.

[0070] Subsequently, after the UV-ray hardening sealant pattern **510** is formed, liquid crystal droplets are dispensed on the alignment-treated first substrate **500**. The second substrate **550** is disposed over the first substrate **500** and is then bonded to the first substrate **500**.

[0071] The common and pixel electrodes **513** and **514** may be formed on different layers. They may also be formed on the same layer including the gate insulating layer **520** along with the source and drain electrodes **516** and **517**. In addition, the common electrode **513** may be formed on the same layer along with the gate electrode **509**, and the pixel electrode **514** may be formed on the passivation layer **525**. Moreover, both of the common and pixel electrodes **513** and **514** may be formed on the passivation layer **525**.

[0072] Therefore, the common and pixel electrodes **513** and **514** may be located regardless of the structure of the liquid crystal display device for the horizontal electrical field system.

[0073] The liquid crystal display device according to the present invention may have the same structure as shown in FIG. 3E.

[0074] As shown in FIG. 3E, a metal layer is deposited on a first substrate **600** and treated with photolithography and etching processes. A plurality of gate lines **649** and gate electrodes **609** are then formed thereon. Simultaneously, a plurality of gate electrodes **609** are formed on a region for a thin film transistor. And, a gate insulating layer **620** is formed on the entire exposed surface of the first substrate **600** including the gate electrode **609**.

[0075] After a semiconductor layer **615** as an active layer is formed on the gate insulating layer **620**, source and drain electrodes **616** and **617** are formed on both corresponding sides of the semiconductor layer **615** on the gate insulating layer **620**.

[0076] After a passivation layer **625** is formed on the entire exposed surface of the gate insulating layer **620** including the source and drain electrodes **616** and **617**, a pixel electrode **614** is formed on the passivation layer **625**.

[0077] Thereafter, a first alignment layer **631** is formed on the entire exposed surface of the passivation layer **625** including the pixel electrode **614**.

[0078] Meanwhile, a black matrix **621** preventing light leakage is formed on a second substrate **650**, and a color filter layer **622** of R/G/B is formed on the second substrate **650** between the black matrix **621**.

[0079] Subsequently, a common electrode **626** is formed on the color filter layer **622** and the black matrix **621**.

[0080] Finally, a first column spacer **605** is formed inside the array region on the second substrate **650**. Simultaneously, a second column spacer **605a** is formed on the common electrode **626** in the periphery of the array region. Moreover, a third column spacer **605b** is formed on the common electrode **626** in the periphery of the second column spacer.

[0081] Meanwhile, a UV-ray hardening sealant pattern **610** is formed between the second column spacer **605a** and the third column spacer **605b**. Therefore, the third column spacer **605b** is formed on the common electrodes **605b** in the periphery of the UV-ray hardening sealant pattern **610**.

[0082] Subsequently, a second alignment layer **635** is formed on the entire surfaces of the common electrode **626** and the first and second column spacers **605** and **605a** in the liquid crystal display panel region. The third column spacer **605b** is formed on the common electrode **626**. Herein, the second alignment layer **635** is not formed on the third column spacer **605b**.

[0083] After the UV-ray hardening sealant pattern **610** is formed, liquid crystal droplets are dispensed on the alignment-treated first substrate **600**. The second substrate **650** is disposed over the first substrate **600**, and then a process of bonding the first and second substrate **600** and **650** to each other is carried out.

[0084] The above-explained structure may be applied to various modes, such as vertical alignment (VA) mode, optically compensated birefringence (OCB) mode, ferroelectric liquid crystal (FLC) mode, reflective mode, and TN mode.

[0085] Meanwhile, as shown in FIGS. 3A, 3C, and 3D, an overcoat layer may be additionally formed on the color filter layer **622**.

[0086] FIG. 3F schematically illustrates a magnified view of an area "A" in FIG. 3E.

[0087] As shown in FIG. 3F, the second and third column spacers 605a and 605b are formed on both sides of the UV-ray hardening sealant pattern 610, so as to maintain a uniform cell gap between the substrates 600 and 650 as well as to reduce a stress caused by a height difference between the substrates 600 and 650.

[0088] The third column spacer 605b, located at the periphery of the UV-ray hardening sealant pattern 610, is located in a position where the bonded substrates 600 and 650 are cut and removed. Hence, the third column spacer 605b may be cut after the liquid crystal display panel is completed.

[0089] FIG. 4A illustrates a layout of a liquid crystal display device fabricated by a liquid crystal dropping method according to the present invention.

[0090] Referring to FIG. 4A, after thin film transistors are formed on a first substrate 700 in a liquid crystal display panel region having an active area 720 and a dummy area 730, silver (Ag) patterns are formed on the first substrate 700 at the periphery of the liquid crystal display panel region. Liquid crystal droplets are dispensed on the first substrate 700 inside the liquid crystal display panel region.

[0091] Meanwhile, a color filter pattern is formed on a second substrate 750. Subsequently, a first column spacer 705 is formed on a wiring part of the array region on the first substrate 700 except for the pixel regions 712. Second column spacers 715 are formed between the inside of the UV-ray hardening sealant pattern 710 and the outside of the array region 720. Moreover, a third column spacer 725 is formed on the outside of the UV-ray hardening sealant pattern 710.

[0092] The first to third column spacers 705, 715, and 725 formed of an organic resin material are formed on the second substrate 750. Exposure and development processes are carried out on the organic resin material, in order to form the first to third column spacers 705, 715, and 725.

[0093] After liquid crystal droplets are dispensed on the first substrate 700, the second substrate 750 is disposed over the first substrate 700 to face into the first substrate 700. The substrates 700 and 750 are then bonded to each other to form a liquid crystal display panel. Thereafter, a UV-ray is irradiated to the bonded substrates 700 and 750 initially on a lower side of the first substrate 700 to harden the UV-ray hardening pattern 710.

[0094] The UV-ray hardening sealant pattern 710 may have a line width smaller or greater than that of the black matrix pattern 730 formed on the second substrate 750. Meanwhile, the UV-ray hardening sealant pattern 710 may shrink occasionally when hardening with UV-ray. Hence, a thermo-hardening sealant may be added to the material of the UV-ray hardening sealant pattern 710.

[0095] Therefore, due to the first column spacers 705 in the array region 720, the cell gap in the array region 720, or the active area, is uniformly maintained in the entire area of the liquid crystal display panel.

[0096] Moreover, the cell gap around the UV-ray hardening sealant pattern 710 is maintained by the second column

spacers 715, formed between the periphery of the array region 720 and the inside of the UV-ray hardening sealant pattern 710, and the third column spacer 725, formed outside the UV-ray hardening sealant pattern 710. In this case, a line width of each of the first to third column spacers 701, 715, and 725 is selected from a range of about 5 to 30  $\mu\text{m}$ . The first to third column spacers 705, 715, and 725 may be formed of an organic resin material, such as a photo-reactive resin material.

[0097] FIG. 4B schematically illustrates a magnified view of an area "B" in FIG. 4A according to the first embodiment of the present invention.

[0098] Referring to FIG. 4B, the second column spacers 715 are formed between the inside of the UV-ray hardening sealant pattern 710 and the outside of the active area 720. Due to this structure, a cell gap around the UV-ray hardening sealant pattern 710 can be uniformly maintained. Moreover, a stress between the substrates 700 and 750 generated from adhesion of the UV-ray hardening sealant pattern 710 can be removed.

[0099] FIG. 4C schematically illustrates a magnified view of an area "B" in FIG. 4A according to the second to fourth embodiments of the present invention.

[0100] Referring to FIG. 4C, the second column spacers 715 are formed on the second substrate 750 between the inside of the UV-ray hardening sealant pattern 710 and the outside of the active area 720. Simultaneously, the third column spacer 725 is formed on the second substrate 750 outside the UV-ray hardening sealant pattern 710.

[0101] Thus, the first column spacers 705 (shown in FIG. 4A) are formed inside the active area 720, thereby uniformly maintaining a cell gap inside the active area 720. Meanwhile, since the second column spacers 715 are formed inside the UV-ray hardening sealant pattern 710, and the third column spacers 725 are formed outside the UV-ray hardening sealant pattern, a cell gap surrounding the UV-ray hardening sealant pattern 710 can be uniformly maintained. In addition, a cell gap across the entire surface of the liquid crystal display panel can also be uniformly maintained.

[0102] More specifically, the second and third column spacers 715 and 725, which are respectively formed inside and outside the UV-ray hardening sealant pattern 710, spread and reduce the stress caused by the UV-ray hardening sealant pattern 710. In this case, at least two of the second and third column spacers are formed inside and outside the UV-ray hardening sealant pattern 710, respectively.

[0103] FIGS. 5A to 5G are layouts and cross-sectional views illustrating a process of fabricating a liquid crystal display device using a liquid crystal dropping method according to the present invention.

[0104] Referring to FIG. 5A, silver (Ag) patterns 801 are formed on a first substrate 800.

[0105] As shown in FIG. 5B, first column spacers 805 are formed inside the active area 820 of a second substrate 850. Second and third column spacers 815 and 825 are formed outside the active area 820 of the second substrate 850.

[0106] The first column spacer 805 is formed on the second substrate 850 corresponding to a wiring part of the first substrate 800. Meanwhile, the second and third column

spacers **815** and **825** are respectively located at the inside and outside areas of a UV-ray hardening sealant pattern **810** that will be formed in a later process.

[0107] Referring to **FIG. 5C**, a UV-ray hardening sealant pattern **810** is formed on the second substrate **850** between the second and third column spacers **815** and **825**.

[0108] As shown in **FIG. 5D**, liquid crystal droplets **803** are dispensed on the first substrate **800**. The second substrate **850** is disposed over the first substrate **800** to face into a bonding machine (not shown), and the first and second substrates **800** and **850** are then bonded to each other.

[0109] More specifically, the second substrate **850** is fixed to an upper stage **870** providing movement in the Z-axis direction (i.e., vertical direction) of the bonding machine. Meanwhile, the silver (Ag) patterns **801** are formed in a region of the first substrate **800** corresponding to the outside area of the UV-ray hardening sealant pattern **810**. Moreover, the first substrate **800** is fixed to a lower stage **860** providing movement in the X and Y axes directions (i.e., horizontal direction) of the bonding machine.

[0110] As shown in **FIG. 5E**, the upper and lower stages **870** and **860** are aligned to each other, and a vacuum condition within the bonding machine is controlled until a desired vacuum level is reached. Hence, the first and second substrates **800** and **850** are bonded to each other. After the substrates **800** and **850** are bonded to each other, the first, second, and third column spacers **805**, **815**, and **825** uniformly form a first cell gap.

[0111] As shown in **FIG. 5E**, the bonded substrates **800** and **850** are exposed to the atmospheric pressure. Nitrogen gas ( $N_2$ ) or air is introduced into a chamber of the bonding machine so as to make a pressure of the chamber become the atmospheric pressure. Accordingly, the substrates bonded with the first gap are under a vacuum condition, and the chamber maintains the atmospheric pressure. Stress is generated between the bonded substrates due to a pressure difference between the inside of the liquid crystal display panel and the atmospheric pressure. Thus, a second cell gap is uniformly formed between the bonded substrates **800** and **850** by the first to third column spacers **805**, **815**, and **825**. Therefore, the dispensed liquid crystal droplets become a liquid crystal layer **803a** having a uniform thickness.

[0112] Referring to **FIG. 5G**, the bonded substrates **800** and **850** are placed on a transparent quartz stage **880**. UV-ray is then irradiated to the UV-ray hardening sealant pattern **810** to harden the UV-ray hardening sealant pattern **810**.

[0113] Accordingly, the liquid crystal display device and the method of fabricating the same according to the present invention have the following effects or advantages.

[0114] The column spacers are formed on at least one of the outside and inside areas of the UV-ray hardening sealant pattern, thereby uniformly maintaining the cell gap surrounding the UV-ray hardening sealant pattern.

[0115] Additionally, since the column spacers are formed on at least one of the outside and inside areas of the UV-ray hardening sealant pattern, stress on the substrates may be released by the UV-ray hardening sealant.

[0116] It will be apparent to those skilled in the art that various modifications and variations can be made in the

liquid crystal display device and the method of fabricating the same of the present invention without departing from the spirit or scope of the inventions. Thus, it is intended that the present invention covers the modifications and variations of this invention provided they come within the scope of the appended claims and their equivalents.

What is claimed is:

1. A method of fabricating a liquid crystal display device, comprising:

preparing first and second substrates having an active area and a dummy area;

forming at least one first column spacer on the active area on the second substrate;

forming at least one second column spacer in the dummy area on the second substrate;

forming a sealant in a periphery of the active area of the second substrate; and

bonding the first and second substrates to each other.

2. The method of claim 1, wherein the sealant includes a photo-hardening sealant.

3. The method of claim 1, wherein the sealant includes a mixture of a thermo-hardening sealant and a photo-hardening sealant.

4. The method of claim 1, wherein the first and second column spacers are about 5 to 30  $\mu m$  in width.

5. The method of claim 1, wherein the first and second column spacers are formed of organic resin.

6. The method of claim 1, further comprising forming at least one third column spacer outside the active area of the second substrate.

7. The method of claim 6, wherein the third column spacer is about 5 to 30  $\mu m$  in width.

8. The method of claim 6, wherein the third column spacer is formed of organic resin.

9. The method of claim 1, further comprising forming a liquid crystal layer between the first and second substrates.

10. The method of claim 9, wherein the liquid crystal layer is applied on the first substrate.

11. The method of claim 1, further comprising forming a sliver pattern in a periphery of the active area of the first substrate.

12. The method of claim 1, wherein the bonding the first and second substrates to each other includes:

loading the second substrate on an upper stage of a bonding machine to face into the first substrate;

loading the first substrate on a lower stage of the bonding machine;

evacuating a chamber of the bonding machine;

aligning the first and second substrates; and

attaching the first and second substrates to each other.

13. The method of claim 12, further comprising venting the chamber to an atmospheric pressure to press the attached substrates by difference between an inner pressure of the bonded substrates and the atmospheric pressure.

14. The method of claim 12, further comprising applying a UV-ray to the attached substrates to harden the sealant.

15. The method of claim 1, wherein the first column spacer is formed on the wiring part of the first substrate.

- 16.** The method of claim 1, further comprising:  
forming a black matrix and a color filter layer on the  
second substrate; and  
forming an overcoat layer on the color filter layer.  
**17.** The method of claim 16, wherein the overcoat layer is  
patterned.

**18.** The method of claim 16, wherein the sealant has a line  
width smaller or greater than the black matrix.

**19.** The method of claim 1, further comprising forming a  
dummy color filter layer on the periphery of the active area  
of the second substrate.

\* \* \* \* \*

专利名称(译)	液晶显示装置及其制造方法		
公开(公告)号	<a href="#">US20040160568A1</a>	公开(公告)日	2004-08-19
申请号	US10/779842	申请日	2004-02-18
[标]申请(专利权)人(译)	乐金显示有限公司		
申请(专利权)人(译)	LG.PHILIPS LCD CO. , LTD.		
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IPC分类号	G02F1/1339		
CPC分类号	G02F2001/13415 G02F1/1339		
优先权	1020010083218 2001-12-22 KR		
其他公开文献	US7433014		
外部链接	<a href="#">Espacenet</a> <a href="#">USPTO</a>		

## 摘要(译)

在本发明中公开了一种液晶显示装置及其制造方法。该装置包括彼此粘合的第一和第二基板，每个基板具有分成有源区和虚设区的液晶显示板区，在液晶显示板区周边的密封剂将第一和第二基板粘合到每个另外，在虚设区域中和液晶显示板区域外部的至少一个柱状间隔物保持第一和第二基板之间的单元间隙，以及第一和第二基板之间的液晶层。

